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PPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION N
09/836,426	04/17/2001	Tim Dyer	35013.4000	6845
75	90 08/01/2002			
Snell & Wilmo	er LLP	EXAMINER		
One Arizona Ce 400 E. Van Bur		MCDONALD, SHANTESE L		
Phoenix, AZ 8	5004-2202	ART UNIT	PAPER NUMBER	
			3723	

DATE MAILED: 08/01/2002

Please find below and/or attached an Office communication concerning this application or proceeding.

Office Action Summary

Application No. 09/836,426

Applicant(s)

Dyer et al.

Examiner

Shantese McDonald

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	- The MAILING DATE of this communication appears	on the	cover she	The MAILING DATE of this communication appears on the cover sheet with the correspondence address							
	for Reply										
A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE3 MONTH(S) FROM THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.136 (a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the											
mailing - If the p - If NO p - Failure - Any re	date of this communication. Deriod for reply specified above is less than thirty (30) days, a reply within the period for reply is specified above, the maximum statutory period will apply at to reply within the set or extended period for reply will, by statute, cause the ply received by the Office later than three months after the mailing date of the patent term adjustment. See 37 CFR 1.704(b).	e statute nd will e e applica	ory minimum o expire SIX (6) I	of thirty (30 MONTHS fi ne ABANDO	D) days will be considered timely. rom the mailing date of this communication. DNED (35 U.S.C. § 133).						
Status											
1) 💢	Responsive to communication(s) filed on Apr 17, 20	<u> </u>			·						
2a) 🗌	This action is FINAL . 2b) 💢 This action is non-final.										
3) 🗌	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11; 453 O.G. 213.										
Disposi	tion of Claims										
4) 💢	Claim(s) <u>1-33</u>				is/are pending in the application.						
4	la) Of the above, claim(s)				is/are withdrawn from consideration.						
5) 🗆	Claim(s)				is/are allowed.						
6) 💢	Claim(s) 1-33		<u> </u>		is/are rejected.						
7) 🗌	Claim(s)				is/are objected to.						
8) 🗌	Claims		are	subject	to restriction and/or election requirement.						
Applica	tion Papers										
9) 🗆	The specification is objected to by the Examiner.										
10)	The drawing(s) filed on is/are	a) 🗆	accepted	d or b)[\square objected to by the Examiner.						
	Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).										
11)	The proposed drawing correction filed on		is:	a) 🗌 a	approved b) \square disapproved by the Examiner.						
	If approved, corrected drawings are required in reply t	o this	Office act	ion.							
12)	The oath or declaration is objected to by the Exami	ner.									
Priority	under 35 U.S.C. §§ 119 and 120										
13)	3) Acknowledgement is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).										
a) 🗆	☐ All b)☐ Some* c)☐ None of:										
	1. \square Certified copies of the priority documents have	e bee	n received	d.							
	2. \square Certified copies of the priority documents have	e bee	n received	in App	olication No						
	3. Copies of the certified copies of the priority do application from the International Burea	au (PC	CT Rule 1	7.2(a)).	·						
	ee the attached detailed Office action for a list of the		•								
14) ∐	Acknowledgement is made of a claim for domestic										
a) U The translation of the foreign language provisional application has been received.											
15)	Acknowledgement is made of a claim for domestic	priori	ty under t	35 U.S.	C. 33 120 and/or 121.						
Attachm	ient(s) otice of References Cited (PTO-892)	م ر ا	Intervious Com	/DT/	O-413) Paper No(s)						
~	otice of Dreftsperson's Patent Drawing Review (PTO-948)			•							
	2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 5) Notice of Informal Patent Application (PTO-152) 3) Information Disclosure Statement(s) (PTO-1449) Paper No(s). 6) Other:										
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DETAILED ACTION

Claim Rejections - 35 USC § 112

1. The following is a quotation of the second paragraph of 35 U.S.C. 112:

The specification shall conclude with one or more claims particularly pointing out and distinctly claiming the subject matter which the applicant regards as his invention.

2. Claims 2 and 4 are rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention.

The claims list the limitations of the platen rotating at a about 1000 orbits per minute. Is it rotating or orbiting?

Claim Rejections - 35 USC § 103

- 3. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 4. Claims 1-9, 26-29, 32 and 33 are rejected under 35 U.S.C. 103(a) as being unpatentable over Lougher et al.

Lougher et al. teaches a platen, 211, configured to orbit, (col. 5, lines 46-52), a polishing surface, 108, attached to the platen, a workpiece carrier, 110 and channels in the platen

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configured to allow polishing solution to circulate through, (col. 5, lines 29-34). Lougher et al. teaches all the limitations of the claims except for the platen orbiting about an axis at a speed of about 500 to 2000 revolutions per minute, the platen rotating with an orbital radius of about 0.25 to 1 inch, the carrier and the platen being configured to move the workpiece relative the polishing surface at about 0.8 to 3.2 meters per second, the carrier being configured to apply about 0.25 to 2 pounds per square inch of pressure to the workpiece, allowing the polishing slurry to flow at a rate of about 120 to 200 milliliters per minute. It would have been obvious to one having ordinary skill in the art at the time the invention was made to make the invention of Lougher et al. with the above listed limitation, since it has been held that where the general conditions of a claim are disclosed in the prior art, discovering the optimum or workable ranges involves only routine skill in the art.

5. Claim 10 is rejected under 35 U.S.C. 103(a) as being unpatentable over Lougher et al. as applied to claims 1-9, 26-29, 32 and 33 above, and further in view of Chen et al.

Lougher et all teaches all the limitations of the claims except for the carrier including a bladder to regulate pressure applied to the workpiece. Chen et al. teaches a bladder, 144. It would have been obvious to one having ordinary skill in the art at the time the invention was made, to provide the carrier of Lougher et al. with a bladder, in order to more efficiently regulate the pressure applied to the workpiece.

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6. Claims 11, 30 and 31 are rejected under 35 U.S.C. 103(a) as being unpatentable over Lougher et al as applied to claims 1-9, 26-29, 32 and 33 above, and further in view of Kawamoto et al.

Lougher et al. teaches all the limitations of the claims except for the platen including a conduit configured to allow heat exchange fluid to flow through, thereby regulating the temperature of the polishing surface and the polishing fluid. Kawamoto et al. teach a conduit configured to allow heat exchange fluid to flow through, (col. 4, lines 25-36). It would have been obvious to one having ordinary skill in the art at the time the invention was made, to provide the platen of Lougher et al. with a conduit to allow heat exchange fluid to flow through, as taught by Kawamoto et al. in order to enhance the temperature control of the polishing apparatus.

7. Claims 12-17, 20 and 25 are rejected under 35 U.S.C. 103(a) as being unpatentable over Chen et al. in view of Aizawa.

Chen et al. teaches a plurality of polishing stations, 25, a platen, 30, a load station, 27, a carousel, 60, including a plurality of workpiece carriers, configured to rotate about an axis and translate in a radial direction, (col. 4, lines 16-20). Chen et al. teaches all the limitations of the claims except for a clean system, a buff station, the platen being configured to move at about 0.8 to 3.2 meters per second relative to the wafer surface, the carrier being configured to apply about 0.25 to 2 pounds per square inch of pressure to the workpiece, the platen being configured to orbit with a radius of about 0.25 to about 1 inch, and the platen being configured to orbit about an axis at a speed of about 500 to 2000 revolutions per minute. Aizawa et al. teaches a

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clean station, 26a, 26b, 26c, and a buffing station, 200. It would have been obvious to one having ordinary skill in the art at the time the invention was made, to make the invention of Chen et al. with a clean station and buffing station, as taught by Aizawa et al., in order to enhance the machines polishing capabilities. It would have been further obvious to make the invention of Chen et al. as modified by Aizawa et al. with the limitations state above, since it has been held that where the general conditions of a claim are disclosed in the prior art, discovering the optimum or workable ranges involves only routine skill in the art.

8. Claims 18, 19, 22 and 24 rejected under 35 U.S.C. 103(a) as being unpatentable over Chen as modified by Aizawa as applied to claims 12-17, 20 and 25 above, and further in view of Lougher et al.

Chen as modified by Aizawa teaches all the limitations of the claims except for a platen configured to orbit, with channels to allow polishing fluid to flow through and a polishing surface which allows the polishing fluid to circulate through a portion of the polishing surface. Lougher et al. teaches a platen configured to orbit, (col. 5, lines 46-52), and channels in the platen and polishing pad which allow the polishing fluid to flow through, (col. 5, lines 29-34). It would have been obvious to one having ordinary skill in the art at the time the invention was made, to provide the apparatus of Chen as modified by Aizawa, with the orbiting platen and channels in the platen and polishing pad, as taught by Lougher et al., in order to enhance the polishing capabilities.

9. Claims 21 and 23 are rejected under 35 U.S.C. 103(a) as being unpatentable over Chen as modified by Aizawa and further in view of Kawamoto et al.

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Chen as modified by Aizawa teaches all the limitations of the claims except for a

temperature control system and the platen allowing heat exchange fluid to flow through.

Kawamoto et al. teach a platen configured to allow heat exchange fluid to flow through, thereby

regulating the temperature of the polishing fluid, (col. 4, lines 25-36). It would have been

obvious to one having ordinary skill in the art at the time the invention was made, to provide the

platen of Chen as modified by Aizawa with a platen to allow heat exchange fluid to flow through,

as taught by Kawamoto et al. in order to enhance the temperature control of the polishing

apparatus.

10. Any inquiry concerning this communication or earlier communications from the examiner

should be directed to Shantese McDonald whose telephone number is (703) 308-8722.

Shaules Mybonoti

Sintese Lashawn McDonald
Patent Examiner

S.L.M.

July 29, 2002